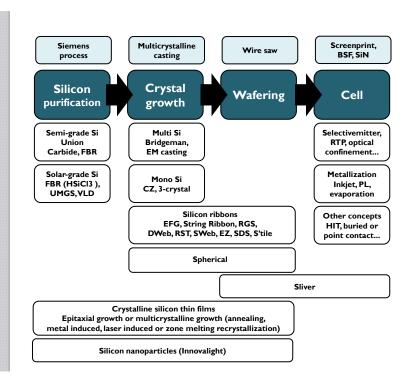


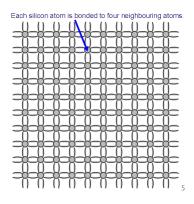


- Is there a c-Si technology?
- Feedstock
- Wafer
- Cells
- Module
- Other silicon concepts
- Materials availability



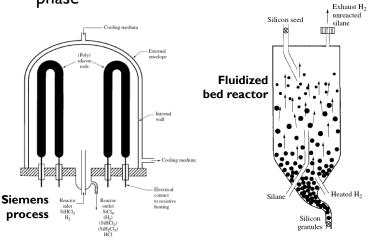


Silicon is the second most abundant element on Earth after oxygen (28% of the Earth's crust). Its most familiar forms are sand and quartzite (the latter one is more pure).



PV TECHNOLOGIES Silicon solar cells

Feedstock: obtaining hyperpure silicon from gas phase





Feedstock: obtaining hyperpure silicon from gas phase



7



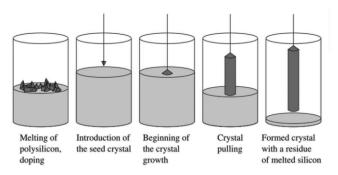
PV TECHNOLOGIES Silicon solar cells

Crystalline silicon may be used in PV in different forms:

Descriptor	Symbol	Grain Size	Common Growth Techniques
Single crystal	sc-Si	>10cm	Czochralski (CZ) float zone (FZ)
Multicrystalline	mc-Si	Imm-I0cm	Cast, sheet, ribbon
Polycrystalline	pc-Si	lµm-lmm	Chemical-vapour deposition
Microcrystalline	μc-Si	<iµm< td=""><td>Plasma deposition</td></iµm<>	Plasma deposition



Czochralski silicon is the standard for electronics industry. High quality (mono) with contamination with oxygen and carbon into the melt.

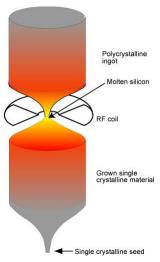






Float zone silicon is the best quality silicon
No contamination but very expensive. Only for very demanding applications.

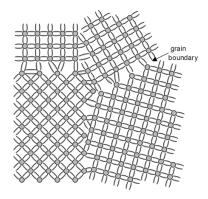




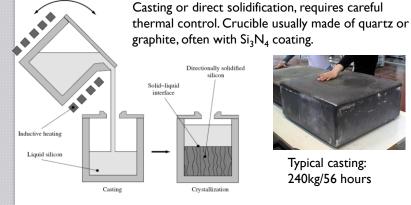
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PV TECHNOLOGIES Silicon solar cells

Multicrystalline silicon offers acceptable quality but at lower cost



Multicrystalline silicon offers acceptable quality but at lower cost.





Typical casting: 240kg/56 hours

13

PV TECHNOLOGIES Silicon solar cells

Multicrystalline ingots require sawing.

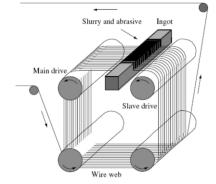
Kerf loss and saw damage removal is significant (and













Multicrystalline wafers may be grown directly in sheet or ribbon form.

- Edge defined film fed growth (EFG)
- String ribbon (SR)
- Ribbon growth on substrate (RGS)
- Dendritic web
- Sheet silicon
- ...

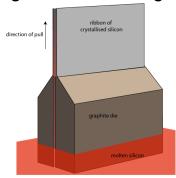
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PV TECHNOLOGIES Silicon solar cells

Multicrystalline wafers may be grown directly in sheet or ribbon form.

• Edge defined film fed growth (EFG)

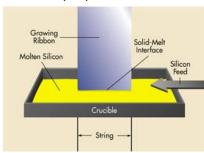






Multicrystalline wafers may be grown directly in sheet or ribbon form.

• String ribbon (SR)



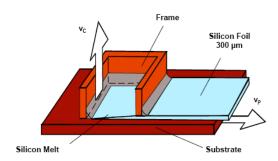
17



PV TECHNOLOGIES Silicon solar cells

Multicrystalline wafers may be grown directly in sheet or ribbon form.

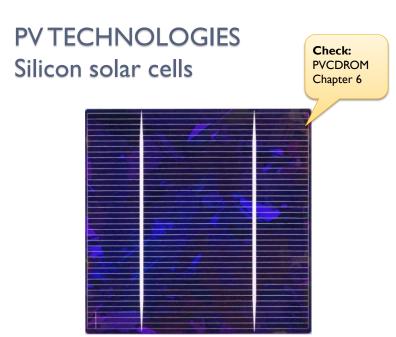
Ribbon growth on substrate (RGS)













Typical screen printed silicon solar cell manufacturing process

- Saw damage etch
- Phosphorous diffusion
- Edge isolation
- Back contact print
- Firing
- Anti reflective coating
- Front contact print
- Firing
- Testing & sorting

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PV TECHNOLOGIES Silicon solar cells

Typical screen printed silicon solar cell manufacturing process

- Saw damage etch
- Phosphorous diffusion
- Edge isolation
- Back contact print
- Firing
- Anti reflective coating
- Front contact print
- Firing
- Testing & sorting



Typical screen printed silicon solar cell manufacturing process

- Saw damage etch
- Phosphorous diffusion
- Edge isolation
- Back contact print
- Firing
- Anti reflective coating
- Front contact print
- Firing
- Testing & sorting

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PV TECHNOLOGIES Silicon solar cells

Typical screen printed silicon solar cell manufacturing process

- Saw damage etch
- Phosphorous diffusion
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- Anti reflective coating
- Front contact print
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Typical screen printed silicon solar cell manufacturing process

- Saw damage etch
- Phosphorous diffusion
- Edge isolation
- Back contact print
- Firing
- Anti reflective coating
- Front contact print
- Firing
- Testing & sorting

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PV TECHNOLOGIES Silicon solar cells

Typical screen printed silicon solar cell manufacturing process

- Saw damage etch
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- Front contact print
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Typical screen printed silicon solar cell manufacturing process

- Saw damage etch
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PV TECHNOLOGIES Silicon solar cells

Typical screen printed silicon solar cell manufacturing process

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Typical screen printed silicon solar cell manufacturing process

- Saw damage etch
- Phosphorous diffusion
- Edge isolation
- Back contact print
- Firing
- Anti reflective coating
- Front contact print
- Firing
- Testing & sorting



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PV TECHNOLOGIES Silicon solar cells

Phosphorous diffusion can be inline continuous or batch type P source: POCl₃







Screenprinting using silver paste is standard.

Inkjet alternatives and/or other materials are fashionable research topics.





PV TECHNOLOGIES Silicon solar cells

Handling thin wafers and keeping high yields may be challenging

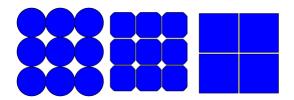






PV silicon module

- Packing density
- Interconnection PV cells
- Encapsulation



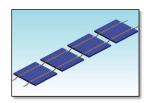
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PV TECHNOLOGIES Silicon solar cells

PV silicon module

- Packing density
- Interconnection PV cells
- Encapsulation



A typical module has 36 celts in series

34

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PV silicon module

- Packing density
- Interconnection PV cells
- Encapsulation
 - Good transmittance but UV absorbance
 - Rigidity to withstand mechanical loads
 - · Protection from weather agents and humidity

Low Ir on Glass

EVA
Tedlar





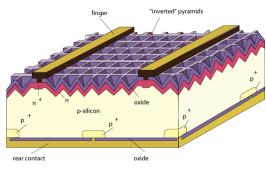
Is there a c-Si technology?

37



PV TECHNOLOGIES Silicon solar cells

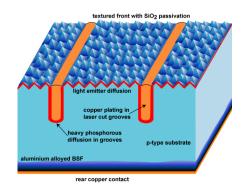
Is there a c-Si technology?
PERL solar cell

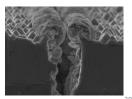






Is there a c-Si technology? Buried contact solar cell

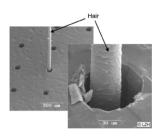




PV TECHNOLOGIES Silicon solar cells

Is there a c-Si technology? Rear interdigitated (RISE) solar cell

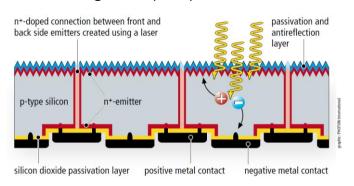






Is there a c-Si technology?

Rear interdigitated (RISE) solar cell



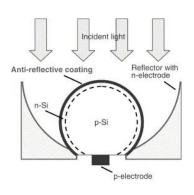
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PV TECHNOLOGIES Silicon solar cells

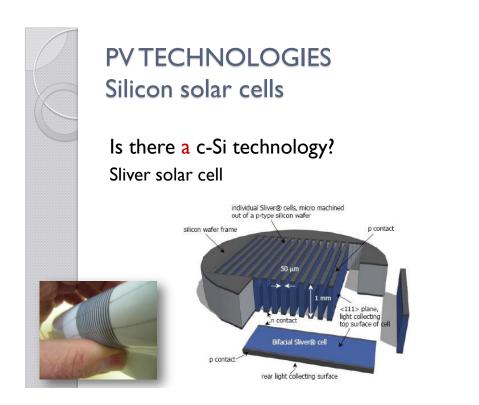
Is there a c-Si technology?

Spheral solar cell









Materials availability

- Silicon is very abundant...
- Silver paste for the contacts will be a material bottleneck
- Other (temporary) bottlenecks:
 - Module glass
 - Tedlar
 - EVA

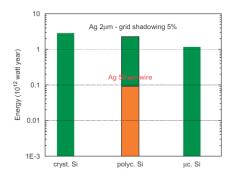
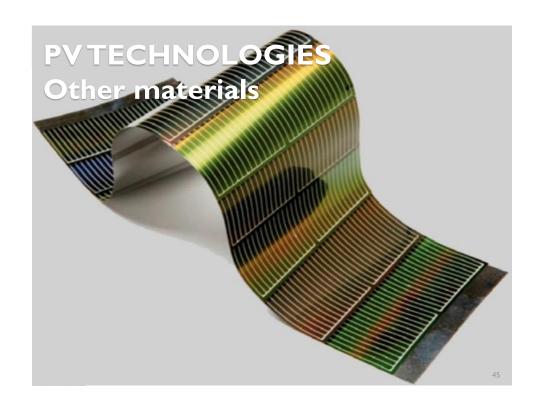


Fig. 3. Potential energy limits imposed by global silver (Ag) reserves for bulk-like silicon photovoltaic technologies. Calculations assume AM1.5 efficiencies of 24.7% (Ref. [8]) and 20.3% (Ref. [7]) for crystalline and large grain poly-crystalline solar cells. The orange shaded area represents limits reached using $50\,\mu m$ -thick Ag ribbons. The green shaded area represents limits estimated using a $2\,\mu m$ thick Ag electrodes and 5% grid shadowing.

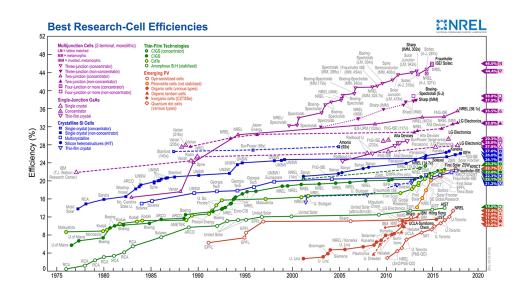
Andrea Feltrin, Alex Freundlich, Material considerations for terawatt level deployment of photovoltaics, Renewable Energy 33 (2008) 180–185





PV TECHNOLOGIES Other technologies

- Other concepts, materials & technologies
 - a-Si
 - CIGS
 - CdTe
- It's not only about efficiency (nor cost!)



4/



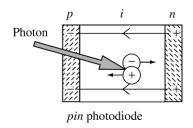
PV TECHNOLOGIES Amorphous silicon solar cells

- Amorphous commonly applied to noncrystalline materials prepared by deposition from gases
- First working a-Si based solar cell: Carlson D,
 Wronski C, Appl. Phys. Lett. 28, 671 (1976)
- Cheaper deposition
- Hydrogenated amorphous silicon (a-Si:H) has higher absorption coefficient than crystalline silicon much thinner ($< I \mu m$) solar cells are possible

PV TECHNOLOGIES Amorphous silicon solar cells

p-i-n configuration

- Electron-hole pairs are generated in the intrinsic 'thick' layer and
- Separated by the built electric field

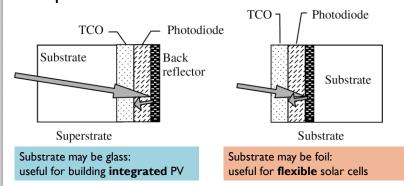


Because doped layers have very little diffusion length...

49

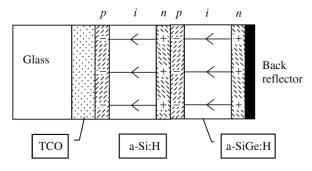
PV TECHNOLOGIES Amorphous silicon solar cells

Very thin active layer ($< I \mu m$) thus: requires substrate





To increase efficiency, more junctions (tandem configuration) may be added



A more modern & fashionable second layer: microcrystalline silicon layer

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PV TECHNOLOGIES Amorphous silicon solar cells

Significant decline in their efficiency during their first few hundred hours of illumination: Staebler—Wronski effect

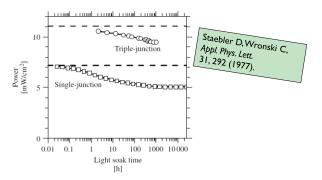
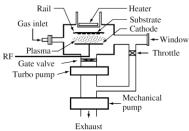


Figure 12.5 The conversion efficiency in a-Si:H-based solar cells declines noticeably upon the first exposure to sunlight. The figure illustrates this decline under a solar simulator (100 mW/cm²) for a single-junction cell (260-nm i-layer thickness) and for a triple-junction module made at United Solar Systems Corp. [14, 15]; the dashed lines indicate the initial power measured for each device

PV TECHNOLOGIES Amorphous silicon solar cells

PECVD - Plasma enhanced chemical vapour deposition (a.k.a. RF glow discharge deposition)

- SiH4 + H2 into the chamber
- RF is applied and generates plasma
- plasma excites and decomposes the gas and generates radicals and ions
- that will diffuse onto the heated substrate



Typical growth speed: I angstrom/sec; Typical substrate temperature: I50-350°C

PV TECHNOLOGIES Amorphous silicon solar cells Oerlikon **Applied Materials** based on process developed at the University of Neuchâtel based on process developed at Research Center Jülich (FZJ) glass SnO₂ coated glass or sputtered - ZnO:Al + HCl etching glass LPCVD - ZnO:B (1 - 1.5 μm) TCO TCO (< 1 µm) a-Si i a-Si PECVD 40 MHz PECVD 13.56 MHz 1.2-1.5 μm 1.2-1.5 µm i μc-Si μc-Si n a-Si sputtered - ZnO:Al (50 - 100 nm) TCO LPCVD - ZnO:B (1 - 1.5 μm) TCO sputtered - Ag (200 nm) metal reflector sputtered - Al (100 nm) white reflector screen printed glass white reflector



In summary:

- Low efficiency (for the same yield requires more area: module framing & encapsulation become relevant costs)
- Low cost (may be interesting if land availability is not an issue)
- Niche markets such as building integrated PV, consumer electronics (i.e. gadgets), flexible solar cells....

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PV TECHNOLOGIES Cadmium Telluride solar cells

- CdTe has a high absorption coefficient: thus very thin active layer
- Earliest paper on CdTe solar cell:
 Loferski J, J. Appl. Phys. 27, 777–784 (1956)
- Most 'popular' configuration: CdTe/CdS heterojunction (p-type CdTe and n-type CdS)

Letters to the Editor

PUBLICATION of brief reports of important discoveries in physics may be secured by addressing them to this department. The closing date for this department is few ewebs prior to the date of issue. No proof will be sent to the authors. The Board of Editors does not held itself repossible for the opinions expressed by the correspondent. Communications should not exceed 600 words in length and should be abunified in duplication.

High-Voltage Photovoltaic Effect*

L. Pensak

RCA Laboratories, Princeton, New Jersey (Received November 25, 1957)

VACUUM evaporated films of cadmium telluride have been prepared that show unusually high photovoltages across their ends. The effect is independent of the electrode material and the voltage is proportional to the length of the film. A value of one hundred volts/cm has been obtained in sunlight. Since the photovoltage of a single junction is limited by the band gap of the material (1.45 ev), it is concluded that the films consist of large numbers of junctions (or other photovoltaic elements) whose individual voltages add to produce the observed values. Photovoltages greater than band gap have been reported for films of PbS, 1-but with a maximum of 3 volts and only after some post-evaporation processing. No such processing is required for the CdTe films.

The presence of the effect depends on the angle, \(\theta \), of deposition of the vapor onto the substrate as shown in Fig. 1. Lines of constant \(\theta \) are found to be equipotentials VACUUM evaporated films of cadmium telluride

Fig. 1. Lines of constant θ are found to be equipotentials Fig. 1. Lines of constant θ are found to be equipotentials for photovoltage. No photovoltage exists in material deposited with θ =0. The photovoltage increases rapidly with θ up to about 10 degrees and then very slowly up to 60 degrees, above which no measurements were taken. A second requirement for the effect is that the substrate be held at a temperature between 100 and 250°C during denosition. The pressure during examples. 250°C during deposition. The pressure during evaporation, $\sim \! 10^{-5}$ mm, is maintained by an oil diffusion pump.

The rate of film formation is about 1000 A per minute. The films become photovoltaic when the thickness is sufficient to absorb some light, and the voltage increases suntrem to answim some ignt, and the voltage increases to a maximum at approximately one micron. The effect occurs with Pyrex glass, fused quartz, and other substrate materials. The only requirement is that the substrate be more insulating than the films which, in the dark, have a resistance of the order of 10¹³ ohms per square at room temperature.

The electrical properties of the films and their re-

The electrical properties of the films and their re-sponse to light and temperature are reported in a following letter. Optical transmission measurements show that the fundamental absorption edge is 8300 A, the expected value for CdTe. X-ray studies by J. G. White of this Laboratory are consistent with the view that the films consist of crystallites whose size is comparable with the film thickness (\sim 1 μ). The crystal-lite (111) planes have a preferred orientation parallel to the substrate, regardless of the angle of deposition. Although the effect has been found in every film made, the magnitude has not been reproducible within a factor of 10. An explicit model for the mechanism of

a factor of 10. An explicit model for the mechanism of the effect has not yet been established. An effect of comparable magnitude has been found in single-crystal zinc sulfide by another group in this laboratory. Further studies of the effect in both materials are under way.

This work was supported by the Evans Signal Corps
 Laboratorics.
 Starkiewicz, Sosnowski, and Simpson, Nature 158, 26 (1946).
 Berlaga, Rusmach, and Strakhov, Zhur. Tekh. Fiz. 25, 1878 (1955).

Properties of Photovoltaic Films of CdTet

B. GOLDSTEIN

RCA Laboratories, Princeton, New Jersey (Received November 25, 1957)

THIS letter describes some of the basic properties of a representative photovoltaic film of CdTe. The film was deposited onto a Pyrex substrate: it was one-half cm long, one cm wide, and about one micron

PV TECHNOLOGIES Cadmium Telluride solar cells

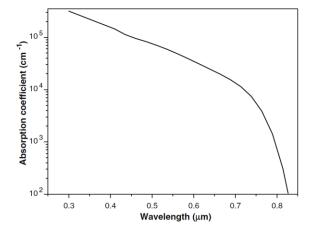


Fig. 5. CdTe absorption coefficient at room temperature.

A. Morales-Acevedo, Thin film CdS/CdTe solar cells: Research perspectives, Solar Energy 80 (2006) 675-681

PV TECHNOLOGIES Cadmium Telluride solar cells

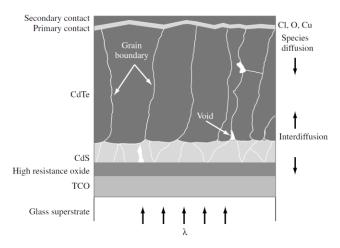
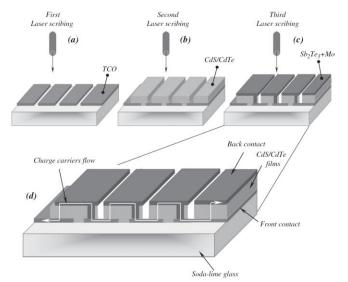


Figure 14.7 Basic CdTe solar cell structure. The polycrystalline nature of the CdS and CdTe layers are indicated schematically and are not to scale

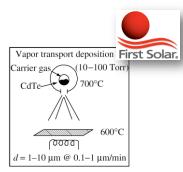
PV TECHNOLOGIES Cadmium Telluride solar cells





PV TECHNOLOGIES Cadmium Telluride solar cells

- Top efficiencies:
 - · Cell 16.7% (NREL);
 - Module 10.9% (BP Solarex);
 - Best seller: First Solar



Main issues:

- Cheapest technology in the market (<I€/Wp)
- 'Limited' efficiency
- Reliability (lifetime)
- Materials!!
 - Toxic Cd
 - Rare Te
- Window of opportunity taken!

6



PV TECHNOLOGIES Cu(InGa)Se₂ solar cells

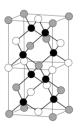
- Synthesis and characterization were first reported by Hahn H et al., Z. Anorg. Allg. Chem. 271, 153–170 (1953)
- High absorption coefficient: thin film
- Like all thin films: potential for cheap manufacturing for fabrication of monolithically interconnected modules
- Potential for relatively high efficiency: 19.4% (cell) and 13.5% (module)

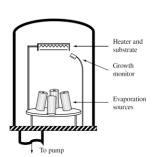


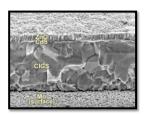
PV TECHNOLOGIES Cu(InGa)Se₂ solar cells

• P-type: Cu(InGa)Se₂

N-type: CdS



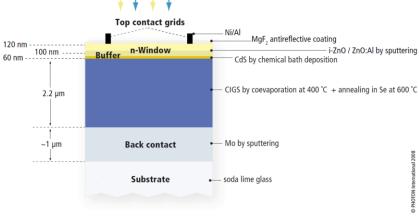




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PV TECHNOLOGIES Cu(InGa)Se₂ solar cells





PV TECHNOLOGIES Cu(InGa)Se₂ solar cells

Other different CIGS concepts...

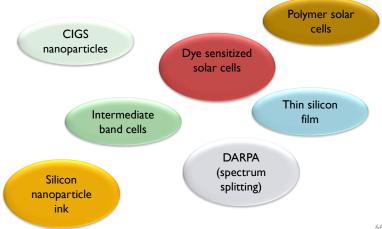


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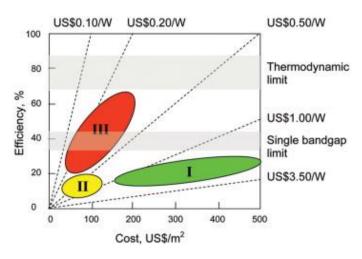


PV TECHNOLOGIES Other technologies

Many other different concepts...



PV TECHNOLOGIES Other technologies



PV TECHNOLOGIES Comparing different technologies



PV TECHNOLOGIES Energy payback time

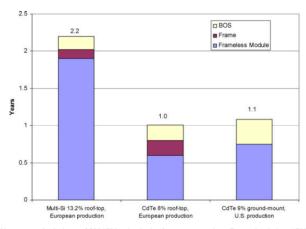


Figure 3. PV energy payback times of 2004 PV technologies for average southern Europe insolation (1700 kWh/m²/yr), 75% performance ratio for roof-top installations, 80% performance ratio for utility ground-mount installations*

V. Fthenakis, E. Alsema, Photovoltaics energy payback times, greenhouse gas emissions and external costs, Prog. Photovolt: Res. Appl. 2006; 14:275–280

69

PV TECHNOLOGIES Energy payback time

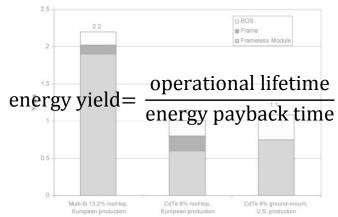
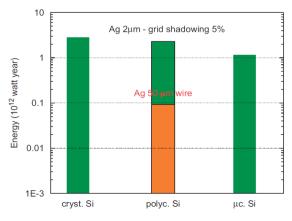


Figure 3. PV energy payback times of 2004 PV technologies for average southern Europe insolation (1700 kWh/m²/yr), 75% performance ratio for roof-top installations, 80% performance ratio for utility ground-mount installations 4-7

PV TECHNOLOGIES Materials availability



Potential energy limits imposed by global silver (Ag) reserves for bulk-like silicon photovoltaic technologies. The orange shaded area represents limits reached using 50 mm-thick Ag ribbons. The green shaded area represents limits estimated using a 2 mm thick Ag electrodes and 5% grid shadowing.

A.Feltrin, A.Freundlich, Material considerations for TW level deployment of PV, Renewable Energy 33 (2008) 180–185

PV TECHNOLOGIES Materials availability

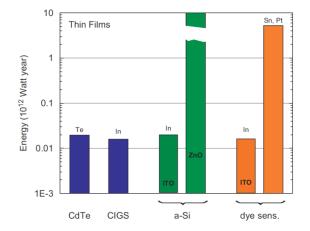


Fig. 4. Potential energy limits imposed for four different thin film photovoltaic technologies.

A.Feltrin, A.Freundlich, Material considerations for TW level deployment of PV, Renewable Energy 33 (2008) 180–185

PV TECHNOLOGIES Materials availability

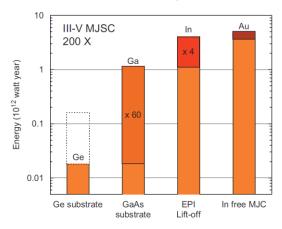


Fig. 5. Potential energy limits imposed to III–V multi-junction cells (200 sun concentrations). The third and fourth columns show the extrapolated potential of this technology if lift-off/cell exfoliation techniques are selected.

A.Feltrin, A.Freundlich, Material considerations for TW level deployment of PV, Renewable Energy 33 (2008) 180–185

7.

PV TECHNOLOGIES Comparing different technologies

Considering all these factors...

- Silicon technologies are to dominate the market in the foreseeable future
- Opportunities for other technologies with industrial scale, in particular CdTe (e.g. First Solar)
- Niche markets are breeding ground for other 'new' technologies (thin films in BIPV or flexible applications, concentration for large solar power plants, etc)